

Density functional theory

The energy of the ground state of a many-electron system : $E_0(\{\mathbf{R}_I\}) = \text{Min}_\Psi \langle \Psi | H^e | \Psi \rangle$

Hohenberg and Kohn (1964): The functional

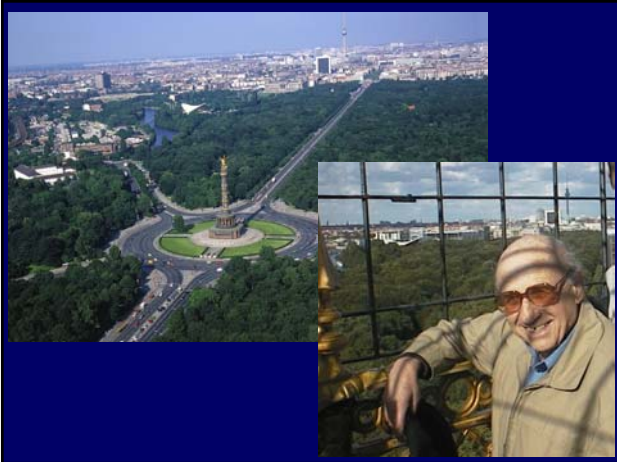
$$n(\mathbf{r}) = n[\Psi] = \langle \Psi | \sum_i \delta(\mathbf{r}-\mathbf{r}_i) | \Psi \rangle$$

can be inverted, *i.e.*,

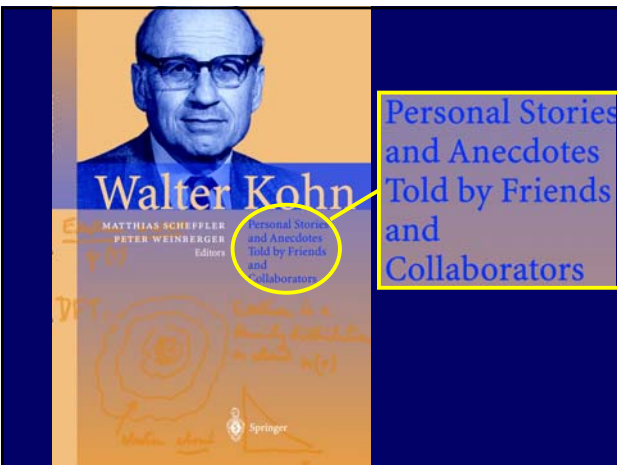
$$\Psi(\mathbf{r}_1, \mathbf{r}_2, \dots, \mathbf{r}_N) = \Psi[n(\mathbf{r})] .$$

This implies:

$$E_0(\{\mathbf{R}_I\}) = \text{Min}_{n(\mathbf{r})} E_{\{\mathbf{R}_I\}}[n]$$







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Kohn and Sham (1965):

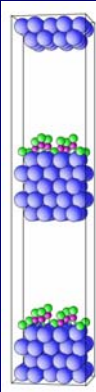
$$E_{\{\mathbf{R}_I\}}[n] = T_s[n] + \int d^3r v_{\{\mathbf{R}_I\}}^{\text{nuc}}(\mathbf{r})n(\mathbf{r}) + \frac{1}{2} \int \int d^3r d^3r' \frac{n(\mathbf{r})n(\mathbf{r}')}{|\mathbf{r} - \mathbf{r}'|} + E^{\text{xc}}[n]$$

with **local-density approximation** or **generalized gradient approximation**

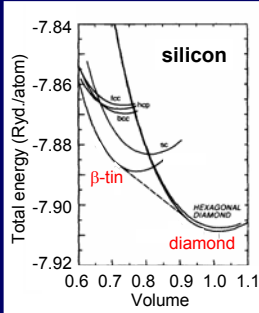
Accuracy of geometries is better than 0.1 Å. Accuracy of calculated energies (relative) is better than 0.2 eV [for special cases better than 0.01 eV].

Methods

- **Density functional theory**
 - **ab initio pseudopotentials** (the fhi98md - code --- www.fhi-berlin.mpg.de/th/th.html)
 - **FP-LAPW** (the WIEN – code by P. Blaha, K. Schwarz, et al.; M. Petersen et al., CPC 126 (2000))
 - **All-electron, numerical basis set** (the DMol³ - code by B. Delley, et al.)
- **ab initio Molecular Dynamics**
- **ab initio Lattice Gas Hamiltonian**
- **ab initio kinetic Monte Carlo**
- **ab initio Quantum Dynamics**



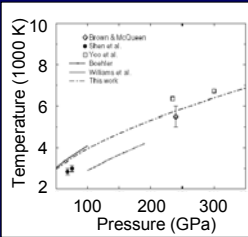
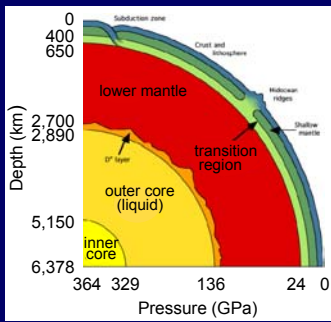
The first (convincing) DFT calculations: Stability of crystals and crystal phase transitions



M. T. Yin and
M. L. Cohen
PRB 26 (1982)

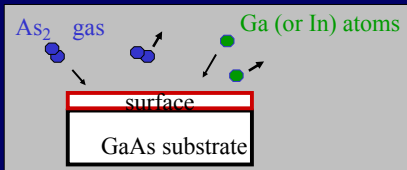
see also:
V.L. Moruzzi, J.F. Janak,
and A. R. Williams
Calculated Electronic
Properties of Metals
Pergamon Press (1978)

Ab initio melting curve of Fe as function of pressure



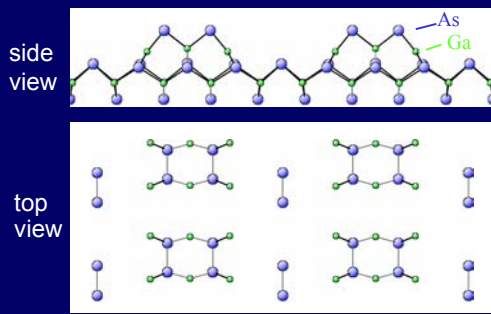
D. Alfe, M. J. Gillan,
and G. D Price
NATURE 401 (1999)

Microscopic processes controlling the growth -- Example: III-V semiconductors



- 1) deposition of Ga and As
- 2) adsorption of Ga
- 3) diffusion of Ga
- 4) desorption of Ga
- 5) adsorption of As₂ ?
- 6) dissociation of As₂ ?
- 7) diffusion of As
- 8) desorption of As
- 9) island nucleation
- 10) growth

β2 Reconstruction of GaAs (001) (2x4) unit cell

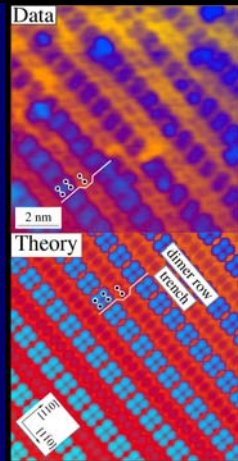


STM Imaging of GaAs(001)

measured filled state image at $V_{tip} = -2.1\text{ eV}$ →

simulated image:
local density of states
integrated to 0.3 eV
below the valence
band maximum →

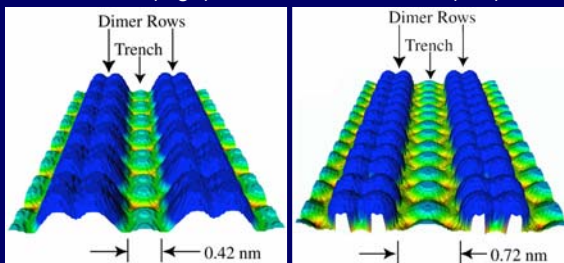
*LaBella, Yang, Bullock,
Thibado, Kratzer & Scheffler,
PRL 83, 2989 (1999).*



Voltage Dependence of the STM Current STM Simulation

-3.0 eV (high)

-2.1 eV (low)



*LaBella, Yang, Bullock,
Thibado, Kratzer & Scheffler,
PRL 83, 2989 (1999).*

Theory of the kinetics of growth

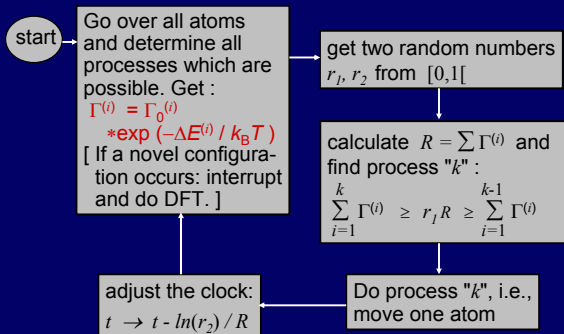
- 1) Analysis of all possibly relevant processes
- 2) Calculate the rates of all important processes

$$\Gamma^{(i)} = \Gamma_0^{(i)} \exp(-\Delta E^{(i)} / k_B T)$$

- 3) Statistical approach to describe
 - deposition
 - diffusion
 - nucleation
 - growth

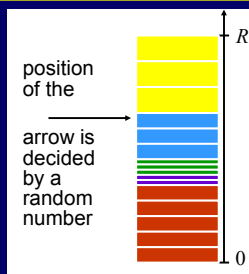
➔ kinetic Monte Carlo method

Flowchart of kinetic Monte Carlo Simulation



➔ unsuccessful processes are avoided

Sketch of the kMC Approach

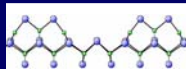


Graphical sketch of the statistics of the process that will be chosen in the kMC approach. Each bar corresponds to a certain atom. The color refers to the type of process, and the thickness to the rate.

for example: **yellow**: Ga diffusion in the trench;
light blue: Ga diffusion perpendicular to trench;
green: Ga enters an As dimer;
dark blue: Ga diffusion parallel to steps;
red: As₂ adsorption into the intermediate.

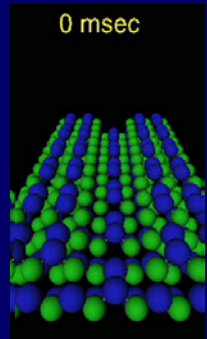
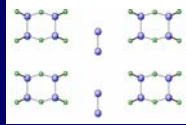
Adsorption, diffusion, island nucleation, and growth of GaAs

side view



Ga
As

top view

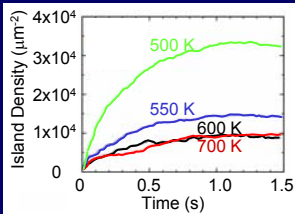


1/60 of the full simulation cell
 As_2 pressure $\approx 1.33 \times 10^{-8}$ bar
 Ga deposition rate = 0.1 ML/s
 $T = 700$ K

P. Kratzer & M. S., PRL 88, 036102 (2002)

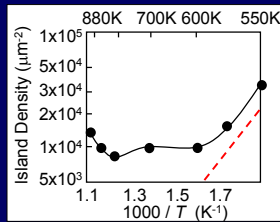
Island density

P. Kratzer & M. S., PRL 88, 036102 (2002)



As_2 pressure = 1.33×10^{-8} bar
 Ga deposition rate = 0.1 ML/s

\log_{10} of island density does not increase linearly with $1/T$: Unusual increase of island density with increasing T (for $T > 800$ K).

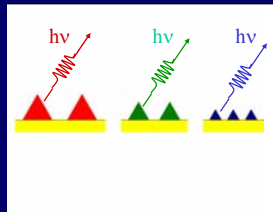


Self-Assembly of Nano-Scale Structures at Semiconductor Surfaces

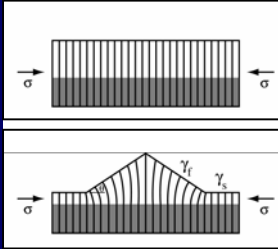
Motivation:

Single-electron transistor

LEDs and laser diodes



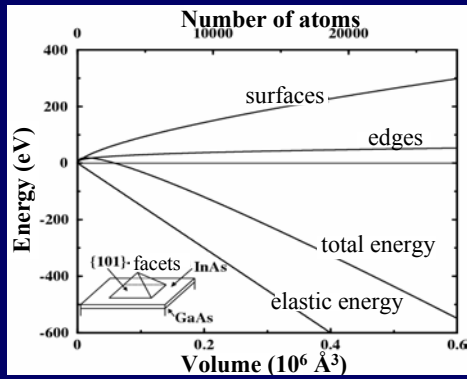
Stranski-Krastanow morphology
as one way to reduce misfit strain energy



e.g.
InAs on
GaAs

For InAs/GaAs the SK model describes
only a part of the full picture

Equilibrium shape of quantum dots

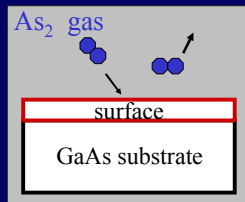


*L. Wang,
P. Kratzer,
and M.S.,
PRL 82
(1999)*

**Stoichiometry and structure
of the surface depend on the environment**

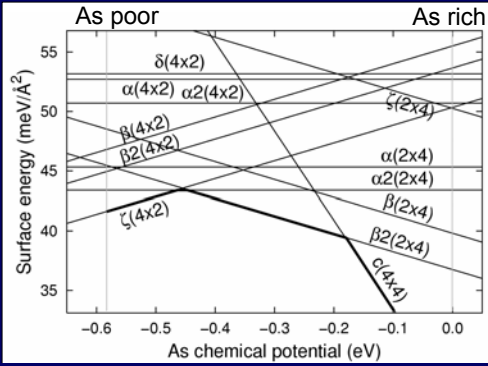
(atomic chemical potentials)

surface energy: $\gamma_0 A_0 = E_{\text{total}} - N_{\text{Ga}} \mu_{\text{Ga}} - N_{\text{In}} \mu_{\text{In}} - N_{\text{As}} \mu_{\text{As}}$



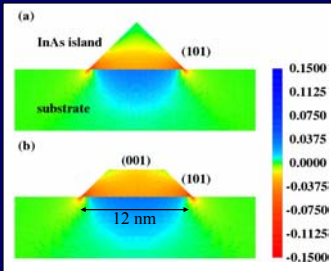
surface stress: $\tau_0 = \gamma_0 + (\partial \gamma / \partial \epsilon)_{\epsilon=0}$

Surface energies of clean GaAs (001)

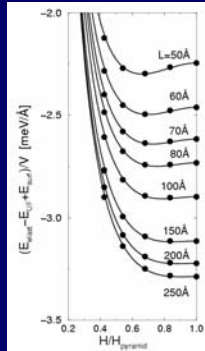


Sung-Hoon Lee, W. Moritz, & M.S., PRL 85, 3890 (2000)

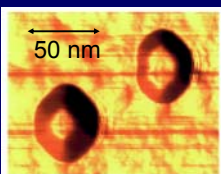
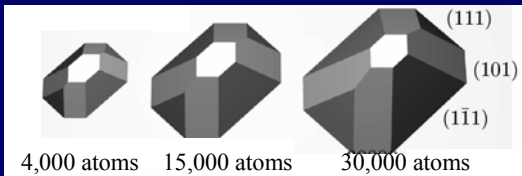
Stress tensor at strained InAs islands on GaAs



N. Moll, M.S., and E. Pehlke, PRB 58, 4566 (1998)



InP quantum dots on GaP(001)



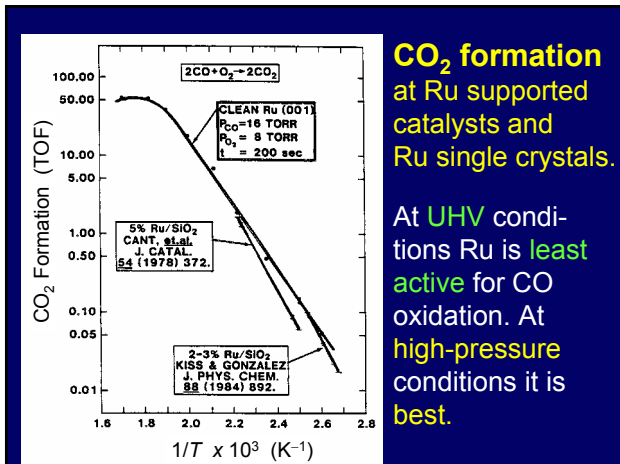
Q. Liu, E. Pehlke, N. Moll, and M.S., PRB 60 (1999)

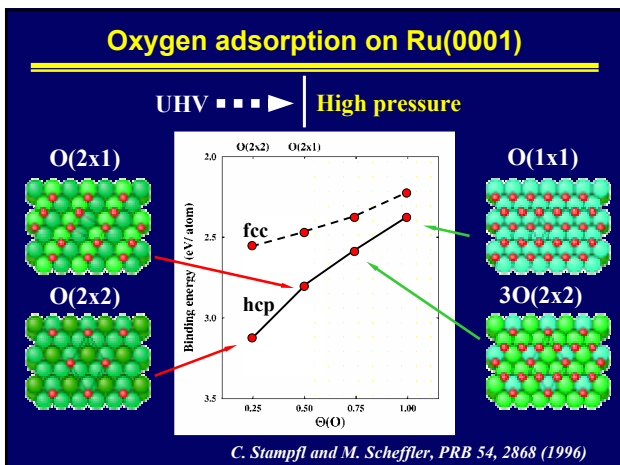
InP islands on GaInP grown by MOVPE
Samuelson et al. (1996)

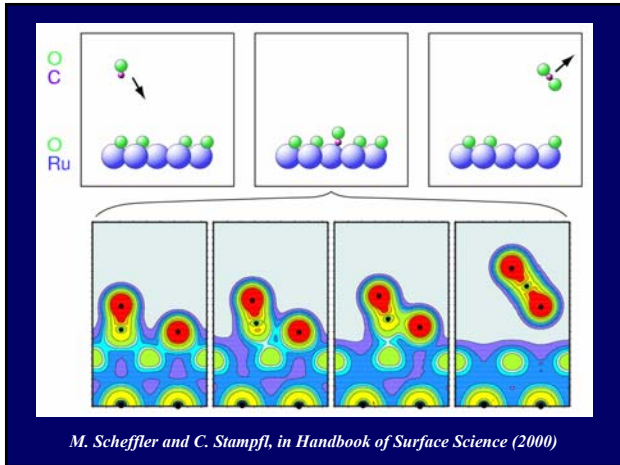
Oxidation catalysis, e.g.:

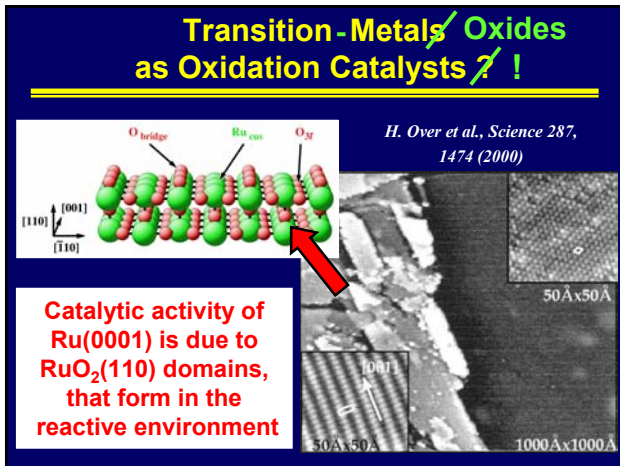


A "simple", prototypical surface chemical reaction









Influence of the environment on surface structure and stoichiometry

$$\gamma_{\text{surface}} = \gamma(T, p) = E_{\text{total}} - N_{\text{O}} \mu_{\text{O}} - N_{\text{Ru}} \mu_{\text{Ru}}$$

surface
RuO₂ substrate

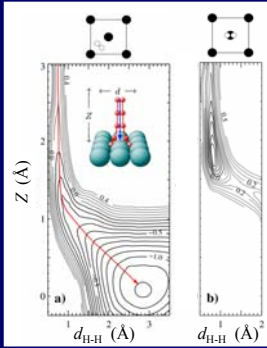
$$\mu_{\text{Ru}} + 2 \mu_{\text{O}} = \mu_{\text{RuO}_2}$$

Only one independent variable:

$$\mu_{\text{O}}(T, p) = \frac{1}{2} \mu_{\text{O}_2}(T, p^0) + \frac{1}{2} kT \ln(p/p^0)$$

C.M. Weinert and M. S., Mater. Sci. Forum 10-12, 25 (1986)
K. Reuter and M.S., PRB 65, 035406 (2002)

"Divide-and-conquer" strategy to determine the reaction dynamics



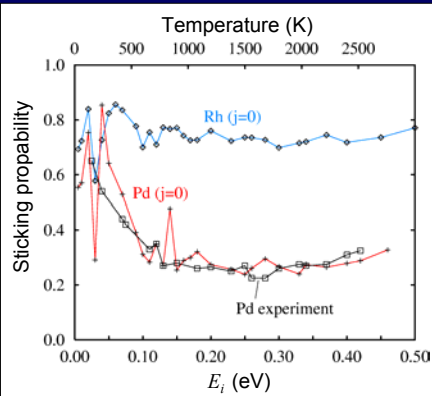
Three independent steps

- 1) Determine potential energy surface (PES) by DFT calculations (GGA for xc)
- 2) Analytical or numerical representation of this PES
- 3) Dynamics
 - a) Solve time-dependent or time-independent Schrödinger equation
 - b) solve Newton's equation of motion

PES for H_2 -- Pd(100)

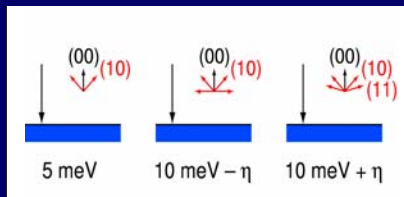
A. Gross and M.S., PRB 57 (1998)

Dissociative adsorption of H_2



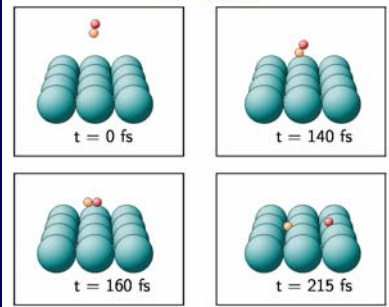
A. Eichler et al., PRB 59 (1999)

Oscillations reflect the threshold, e.g., exit conditions of reflected beams



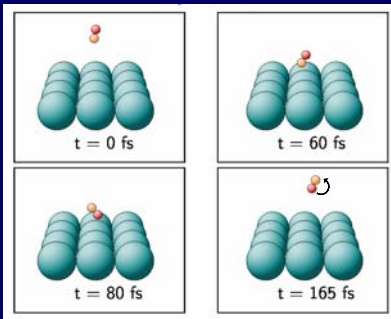
Molecular Dynamics Snapshots of $H_2 \rightarrow Pd(100)$

Steering effect: aligning the incoming molecule
(at low energies; here: $E_i = 0.01$ eV)



*A. Gross
and M.S.,
PRB 57,
(1998)*

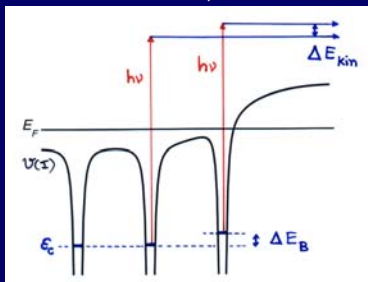
No steering at higher energies; here: $E_i = 0.12$ eV



A. Gross and M.S., PRB 57 (1998)

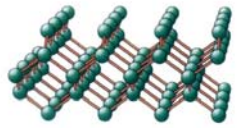
Surface core level shifts (SCLS or ESCA)

Important tool for surface analysis (identification of atoms, electronic structure, nature of bonding).

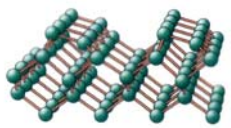


Often surface core-level shifts are interpreted as an **initial-state effect**.

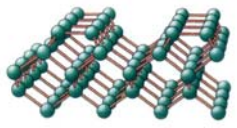
Dimerization and dimer buckling at Si(001)



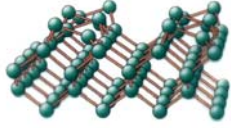
truncated bulk geometry



dimer buckling



formation of dimers

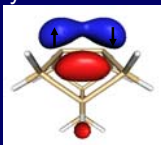


alternating buckling

Buckling at the clean Si(001) surface is sensitive to electron correlation and electron-lattice coupling

"A negative U system" ?

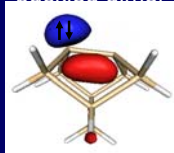
HOMO of symmetric dimer



favored by MCSCF (clusters)

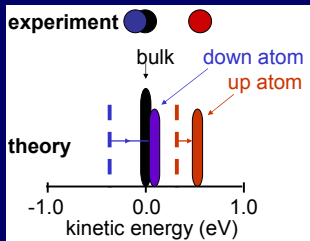
Which configuration is the ground state ?

HOMO of buckled dimer



favored by DFT (slabs)

Si $2p$ SCLS for Si(001) p(2x2)



For this system: screening at the surface is better than in the bulk

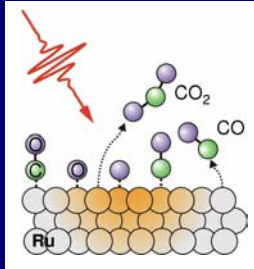
Two peaks = clear proof for the buckling

Theory
dashed: initial-state effect only

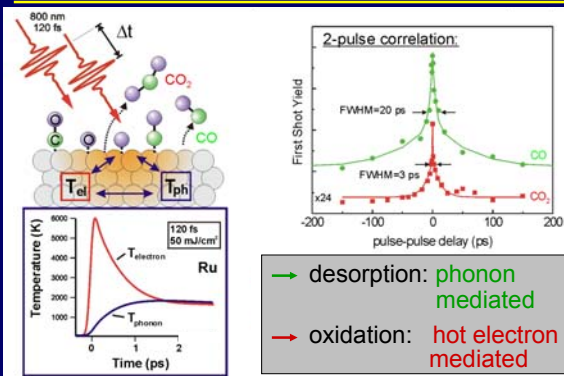
bars: including also final-state screening (by total-energy differences or transition-state theory)

E. Pehlke and M.S., PRL 71, 2338 (1993).

Photochemistry: Phonon- versus electron-mediated surface reactions: Laser-induced desorption and oxidation of CO on Ru(0001)

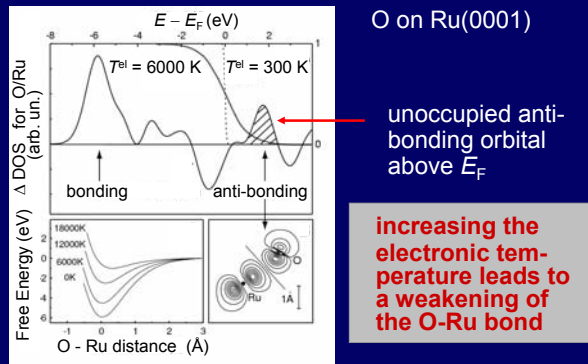


Femtosecond photooxidation of CO on Ru



M. Bonn et al., SCIENCE 285 (1999)

DFT calculations at finite temperature



M. Bonn et al., SCIENCE 285 (1999)

